Preliminary Amendment dated July 28, 2003 Reply to Final Office Action of January 28, 2003

This listing of claims will replace all prior versions, and listings, of claims in the application:

## **Listing of Claims:**

Claim 8 (canceled)

Claim 16 (currently amended): A semiconductor device comprising:

first and second wells opposite in conductivity types and disposed adjacent to each other;

a well isolation structure comprising a shallow trench formed on a boundary of said first and second wells;

a first device region provided in said first well;

a second device region provided in said second well, said first and second device regions being disposed to oppose each other <u>face-to-face</u>, with said well isolation structure disposed between said first and second device regions;

a third device region provided in said first well;

a fourth device region provided in said second well, said third and fourth device regions being disposed not to oppose each other <u>face-to-face</u>, with said well isolation structure disposed between said third and fourth device regions;

wherein a first width of said well isolation structure between said first and second device regions is smaller than a second width of said well isolation structure between said third and fourth device regions.

Claim 17 (previously presented): The semiconductor device according to claim 16, wherein said first, second, third and fourth device regions have substantially same configuration.

Claim 18 (currently amended): A semiconductor device comprising:

a first well of p type and a second well of n type disposed adjacent to each other;

a well isolation structure comprising a shallow trench formed on a boundary of said first and second wells;



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a pair of a first device region of n type and a second device region of p type, said first and second device regions being disposed to oppose each other <u>face-to-face</u>, with said well isolation structure disposed between said first device region and said second device region;

a third device region of n type and fourth device region of p type, said third and fourth device regions being disposed not to oppose each other face-to-face, with said well isolation structure disposed between said third device region and said fourth device region;

wherein said first and third device regions are provided in said first well and said third and fourth device regions are provided in said second well, and a first width of said well isolation structure between said first and second device regions is smaller than a second width of said well isolation structure between said third and fourth device regions.

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